

METHOD OF DOUBLE-SIDED ETCHING

Appl. No. : 10/711,883 Confirmation No. 5882
Applicant : Chen-Hsiung Yang
Filed : October 12, 2004
TC/A.U. : 1765
Examiner : CHEN, KIN CHAN
Docket No. : TMIP0003USA0
Customer No. : 27765

Commissioner for Patents
P.O. Box 1450
Alexandria VA 22313-1450

AMENDMENT

5 In response to the Office action of July 11, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Amendments to the Drawings begin on page 5 of this paper and include both an attached replacement sheet and an annotated sheet showing changes.

10 **Remarks/Arguments** begin on page 6 of this paper.

An **Appendix** including amended drawing figures is attached following page 8 of this paper.